

Data Sheet November 1998 File Number 4542

Radiation Hardened Hex Inverter with Open Drain Outputs

The Radiation Hardened ACS05MS is a Hex Inverter with open drain outputs. This device inverts a HIGH level on each input to a LOW level on the corresponding Y output. A LOW level on the input causes the corresponding Y output to enter a high impedance state, which can be pulled HIGH through a resistor to V_{CC} . All inputs are buffered and the outputs are designed for balanced propagation delay and transition times.

The ACS05MS is fabricated on a CMOS Silicon on Sapphire (SOS) process, which provides an immunity to Single Event Latch-up and the capability of highly reliable performance in any radiation environment. These devices offer significant power reduction and faster performance when compared to ALSTTL types.

Specifications for Rad Hard QML devices are controlled by the Defense Supply Center in Columbus (DSCC). The SMD numbers listed below must be used when ordering.

Detailed Electrical Specifications for the ACS05MS are contained in SMD 5962-98602. A "hot-link" is provided on our homepage with instructions for downloading. www.intersil.com/data/sm/index.asp

Features

- QML Qualified Per MIL-PRF-38535 Requirements
- 1.25 Micron Radiation Hardened SOS CMOS
- Radiation Environment
 - Latch-Up Free Under any Conditions

 - 0_0 == 1 1...oo.loid 1.11111111 7 100...o 1/(...g/o...
- Quiescent Supply Current 100μA (Max)
- Propagation Delay 20ns (Max)

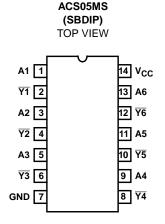
Applications

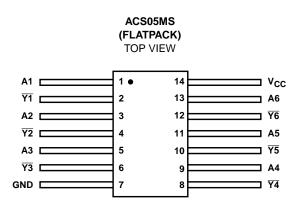
- · High Speed Control Circuits
- · Sensor Monitoring
- · Low Power Designs

Ordering Information

ORDERING NUMBER	INTERNAL MKT. NUMBER	TEMP. RANGE (°C)	PACKAGE	DESIGNATOR
5962F9860201VCC	ACS05DMSR-03	-55 to 125	14 Ld SBDIP	CDIP2-T14
ACS05D/SAMPLE-03	ACS05D/SAMPLE-03	25	14 Ld SBDIP	CDIP2-T14
5962F9860201VXC	ACS05KMSR-03	-55 to 125	14 Ld Flatpack	CDFP4-F14
ACS05K/SAMPLE-03	ACS05K/SAMPLE-03	25	14 Ld Flatpack	CDFP4-F14
5962F9860201V9A	ACS05HMSR-03	25	Die	N/A

Pinouts





ACS05MS

Die Characteristics

DIE DIMENSIONS:

Size: $2390\mu m \times 2390\mu m$ (94 mils x 94 mils) Thickness: $525\mu m \pm 25\mu m$ (20.6 mils ± 1 mil) Bond Pad: $110\mu m \times 110\mu m$ (4.3 x 4.3 mils)

METALLIZATION:

Metal 1 Thickness: $0.7\mu m \pm 0.1\mu m$ Metal 2 Thickness: $1.0\mu m \pm 0.1\mu m$

SUBSTRATE POTENTIAL

Unbiased Insulator

PASSIVATION:

Type: Phosphorous Silicon Glass (PSG)

Thickness: 1.30μm ±0.15μm

SPECIAL INSTRUCTIONS:

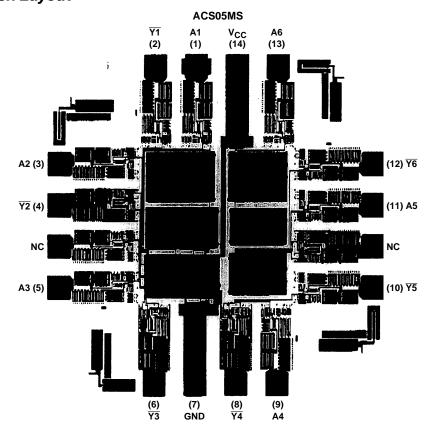
Bond V_{CC} First

ADDITIONAL INFORMATION:

Worst Case Current Density: <2.0 x 10⁵ A/cm²

Transistor Count: 46

Metallization Mask Layout



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